



ONS00555

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Alan R. Ball et al
Serial No.: 10/813501
Filing Date: March 31, 2004
Group Art Unit: 2816
Exa
Title: METHOD OF FORMING A SELF-GATED TRANSISTOR AND
STRUCTURE THEREFOR

DISCLOSURE STATEMENT UNDER 37 C.F.R. 1.56

Honorable Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450
SIR:

It is respectfully requested that the prior art listed on FORM PTO-1449 be considered in the examination of the subject application and made of record therein. A copy of the listed prior art is enclosed herewith.

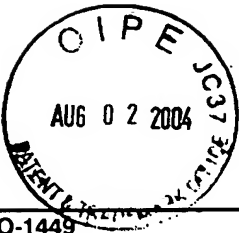
No representation is made or intended that the listed prior art enclosed herewith is material to patentability of the subject patent application.

No representation is made or intended that a search has been made or that no better prior art than that listed is available.

Respectfully submitted,
Alan R. Ball et al.

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Form PTO-1449 LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use Several Sheets if Necessary)	ATTY. DOCKET NO.	SERIAL NO.
	ONS00555	10/813501
	APPLICANT Alan R. Ball et al	
	FILING DATE 3/31/2004	GROUP 2816

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Sub-Class	Filing date (if appropriate)
AA	6 7 4 7 8 8 0	6/8/2004	Grover	H02M	3/335	
AB						
AC						
AD						
AE						
AF						
AG						
AH						
AI						
AJ						
AK						
AL						
AM						

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document #	Date	Country	Class/subclass	Translation Yes - No
AN					
AO					
AP					
AQ					
AR					

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

AS	
AT	
AU	
AV	
AW	

EXAMINER DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.